

Plans Launched for Establishing MRS Washington, DC Office

Several Materials Research Society volunteers from the Washington, DC area met on the morning of January 24 to discuss implementing an MRS Office of Public Affairs. This site inspection and planning meeting was held at the new MRS office's location in the American Geophysical Union Building at 2000 Florida Avenue NW, Washington, DC 20009. It occupies space in the American Institute of Physics complex where the AIP Government Liaison, *Physics Today*, and Education Division offices are also located.

The meeting began the process of implementing a motion proposed to MRS Council by the External Affairs Committee to establish a Washington presence for the

Society. The motion was approved at the 1989 MRS Fall Meeting last December in Boston. The office will enable more effective communications between the Society and congressional offices, federal agencies and other private Washington-based technical organizations concerned with materials research activities, legislation and policies.

"We look forward to better facilitating a flow of information to members about key activities that influence the future and fortunes of materials science and engineering," said Elton N. Kaufmann, chairman of the Subcommittee on Public Affairs of the MRS External Affairs Committee. "As we have often been advised, being close to the

hub of such activities is indispensable to rapid and responsive reporting on developments. We will primarily use the pages of the *MRS Bulletin* to inform the membership," continued Kaufmann, who is also chairman of the Editorial Boards for the *MRS Bulletin*.

For further information on the new MRS Office of Public Affairs, contact the Coordinator of the Implementation Task Group, Graham K. Hubler, Naval Research Laboratory, Code 4671, Washington, DC 20375-5000; telephone (202) 767-4800; or MRS Headquarters at 9800 McKnight Road, Pittsburgh, PA 15237, telephone (412) 367-3003, fax (412) 367-4373.

MRS BULLETIN - EDITORIAL CALENDAR

	<u>News Deadline</u>	<u>Advertising Closing</u>	<u>Publication</u>
April — Materials for Optical Storage Guest Editors: Matthew Libera, IBM Almaden Research Center; Richard J. Gambino, IBM T.J. Watson Research Center	February 1, 1990	March 5, 1990	April 12, 1990
May — To Be Announced	March 1, 1990	April 5, 1990	May 10, 1990
June — High Temperature Superconductors Guest Editor: M. Brian Maple, University of California, San Diego	April 2, 1990	May 4, 1990	June 8, 1990
July — Materials for Vacuum Guest Editor: Alan Krauss, Argonne National Laboratory	May 1, 1990	June 6, 1990	July 11, 1990
August — Materials Education Guest Editor: Reza Abbaschian, University of Florida	June 1, 1990	July 6, 1990	August 10, 1990
September — Interfaces, Part I Guest Editors: Dieter Wolf, Argonne National Laboratory; Sidney Yip, MIT	July 2, 1990	August 6, 1990	September 13, 1990
October — Interfaces, Part II Guest Editors: Dieter Wolf, Argonne National Laboratory; Sidney Yip, MIT	August 1, 1990	September 6, 1990	October 12, 1990
November — Neutron Scattering for Materials Research Guest Editors: Stephen M. Shapiro, Brookhaven National Laboratory; Simon C. Moss, University of Houston	September 4, 1990	October 4, 1990	November 8, 1990
December — To Be Announced	October 1, 1990	November 6, 1990	December 14, 1990

This form is to be used to cover all documentation in support of nominations for the Von Hippel Award. Copies are available from MRS Headquarters, 9800 McKnight Road, Pittsburgh, PA 15237; telephone (412) 367-3003, facsimile (412) 367-4373.

VON HIPPEL AWARD

of the Materials Research Society

Nomination Summary Form

NAME of CANDIDATE:

TITLE and AFFILIATION (present and recent past):

ADDRESS and TELEPHONE:

EDUCATION:

SUMMARY CITATION: (Summarize the professional achievements upon which this nomination is based.) (< 60 words.)

I. Qualification of Nominees

Nominees for the Materials Research Society's Von Hippel Award must have outstanding scientific credentials, their scientific work must have had a significant impact on materials research, and it must have exemplified an interdisciplinary approach. The scientific discipline of the nominee is of no concern except that the work must have been in areas commonly associated with materials research. The nominee does not need to be a member of the Materials Research Society and nominees of any nationality are eligible. It is not necessary for the nominee to have previously won other major awards. We especially hope to identify individuals who have reached the stage in their careers when they will be first considered for major awards.

II. Nomination Package Requirements

1. A statement by the nominator supporting the candidate's suitability for the Award with respect to:
 - interdisciplinary character of the candidate's work
 - manner in which the candidate's work spans basic and applied science
 - impact of the candidate's work within and outside their immediate professional field.
 - Wherever possible, this statement should cite evidence rather than opinion or intuition. Further pertinent information may be added.
2. Supporting information and documents, e.g., lists of the candidate's professional appointments held, honors, awards, patents and publications; the nominator must also provide a separate list of the most important papers and books published by the nominee.
3. Names of three distinguished scientists who have agreed to send letters supporting the nomination with explicit reference to the three criteria of item 1 (above). (Their letters should be sent promptly to the address below.)
4. A list of supporting documents submitted.

A nomination for the Von Hippel Award remains under consideration for three years, so individuals who are nominated in 1990 will remain under consideration through 1992. In preparing nominations, please bear in mind that the nominees for this award should have made outstanding contributions to our profession. Further, since a poorly prepared nomination for an outstanding individual would constitute a disservice to that person, it is important for the nomination package to truly reflect the accomplishments and stature of the nominee.

III. Selection of Von Hippel Award Recipient

The recipient of the Von Hippel Award is determined by a vote of the MRS Council.

IV. Deadline for Submission of Nominations

To be considered for the 1990 Award, the nomination must be submitted by July 1, 1990, to J. Murray Gibson, the MRS Awards Committee, AT&T Bell Laboratories, Room 1E-234, 600 Mountain Avenue, Murray Hill, NJ 07974.

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EQUIPMENT EXHIBIT

1990 MRS Spring Meeting San Francisco Marriott

Tuesday-Thursday, April 17-19, 1990

As part of the 1990 Spring Meeting, a major equipment exhibit will display analytical and processing equipment closely paralleling the nature of the technical symposia. The exhibit will be in the San Francisco Marriott, and the technical program has been arranged to allow meeting participants ample opportunity to visit the exhibit.

Show Hours

Tuesday	Noon - 7:00 p.m.
Reception	5:00 p.m. - 7:00 p.m.
Wednesday	9:00 a.m. - 5:00 p.m.
Thursday	9:00 a.m. - 2:00 p.m.

EXHIBITORS

(as of February 9, 1990)

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| <p>Academic Press
Accufiber, Inc.
AET-Addax
Aixtron GmbH
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